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Mechanisms of Superplastic Deformation of Nanocrystalline Silicon Carbide Ceramics

by Yutaka Shinoda

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14. ABSTRACT This project was undertaken to obtain preliminary data on the effect of nanograin size SiC materials on its properties. Using starting SiC powders with an average particle size of about 30 nm and small amounts of carbon and oxygen impurities, several processing techniques were used to fabricate bulk samples. These included the following: standard hot isostatic pressing (HIP), spark plasma sintering, ultra-high pressure HIP, and a multianvil pressure apparatus. The ultra-high pressure HIP technique achieved a final average grain size less than 100 nm and a relative percent of theoretical density of 96.8%; the hardness of this material was 22.7 GPa. A theoretical analysis of the effect of grain size on critical resolved shear stress to nucleate dislocations suggested a critical grain size of about 400 nm, below where it was easier to move partial dislocations. However, above this size, it was easier to move perfect dislocations. In addition, using more conventional hot-pressing techniques, the effect of different silicon and carbon contents was also investigated. It was found that increases in the free carbon and silicon content decreased the resulting grain size and influenced their strain rate sensitivity and flow stress.					
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Foreword

This project has been co-funded by the U.S. Army International Technology Center - Pacific and the U.S. Army Research Laboratory (ARL) under the direction of Drs. J. W. McCauley and J. P. Singh of ARL.

1. Objective

The aim of the present study is to clarify the effect of the grain size and free-carbon content on the superplastic deformation in order to invent the high-performance nano-silicon carbide (SiC) ceramics and reveal the participation and morphology of dislocation activity in superplastic deformation of nano-SiC ceramics.

2. Results

2.1 Fabrication of Nanocrystalline SiC Ceramics

Nanocrystalline β -SiC powder with a mean particle size of 30 nm (Sumitomo-Osaka Cement Co., Tokyo, Japan, T-1 grade) was sintered without a sintering additive using several methods. The powder contained 3.7 weight-percent free carbon and 0.6 weight-percent impurity oxygen, and the amount of other metallic impurities was less than 1 ppm. Table 1 shows the characteristics of SiC sintered by various sintering methods. Figures 1–4 show the microstructure of the sintered SiC. The grain size decreased with decreasing sintering temperature. The grain size of the sintered body using multianvil apparatus was smallest; however, its hardness was extremely low in spite of relatively high density. The perfect bonding of SiC particles required a higher temperature than 1200 °C. The sintered body via the ultra-high pressure hot isostatic pressure (HIP) exhibited the highest density and highest hardness and fine grain size of less than 100 nm. The ultra-high pressure HIP was effective for fabricating high-quality nanocrystalline SiC ceramics.

Table 1. Characteristics of sintered SiC by various sintering methods.

Sintering Method	Sintering Conditions		Relative Density (%)	Hv (1 kgf) (kgf/mm ²)
	Temperature (C°)	Pressure (MPa)		
Standard HIP	2000	200	93.8	2000
Sinter forging by SPS	1800	500	93.5	2080
Ultra-high pressure HIP	1600	980	96.8	2270
Multianvil apparatus	1200	3000	94.8	1130

Note: SPS = spark plasma sintering.

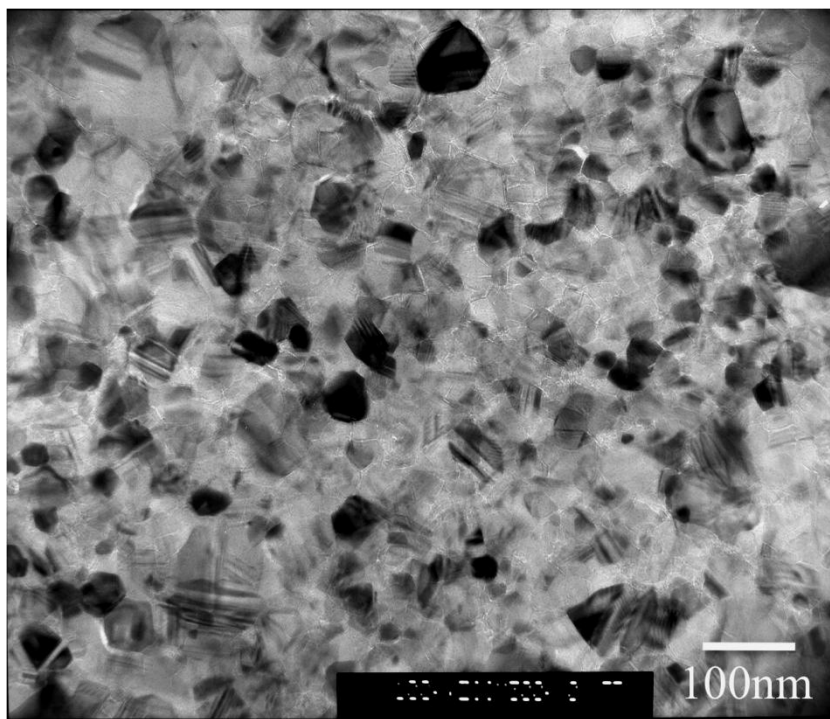


Figure 1. Ultra-high pressure HIP; 1600 °C, 980 MPa.

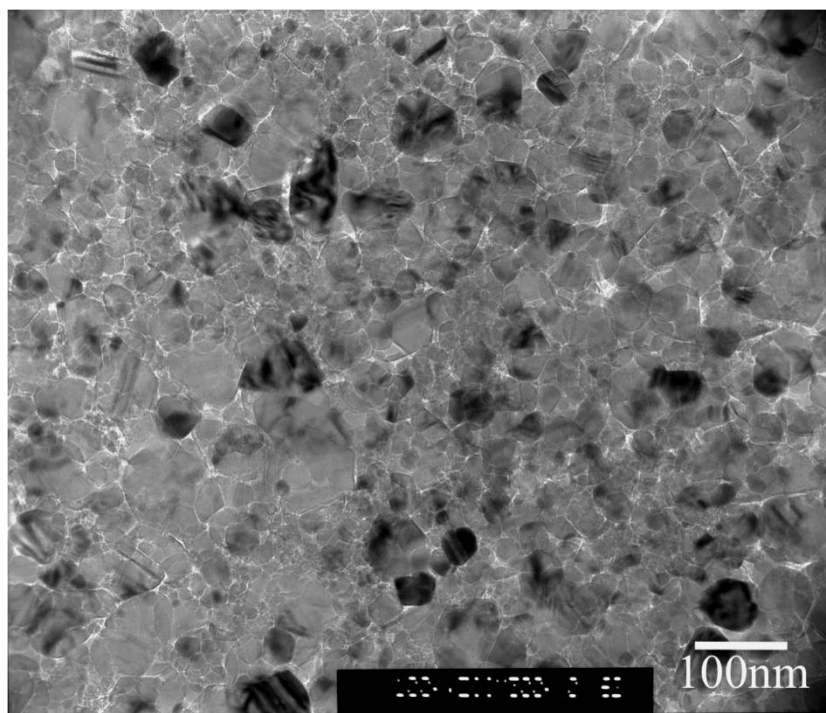


Figure 2. Multianvil high-pressure apparatus; 1200 °C, 3 GPa.

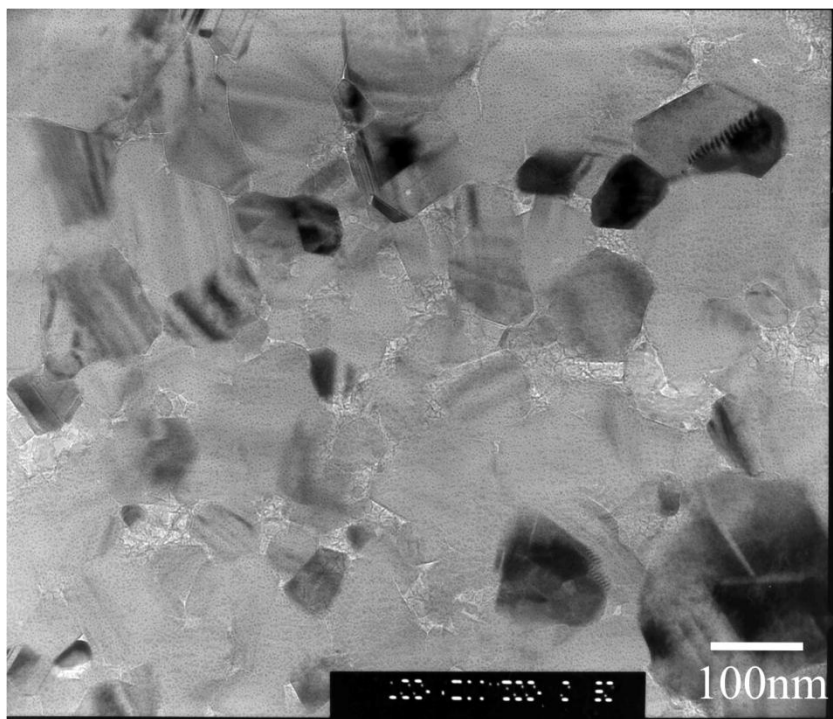


Figure 3. Standard HIP; 2000 °C, 200 MPa.

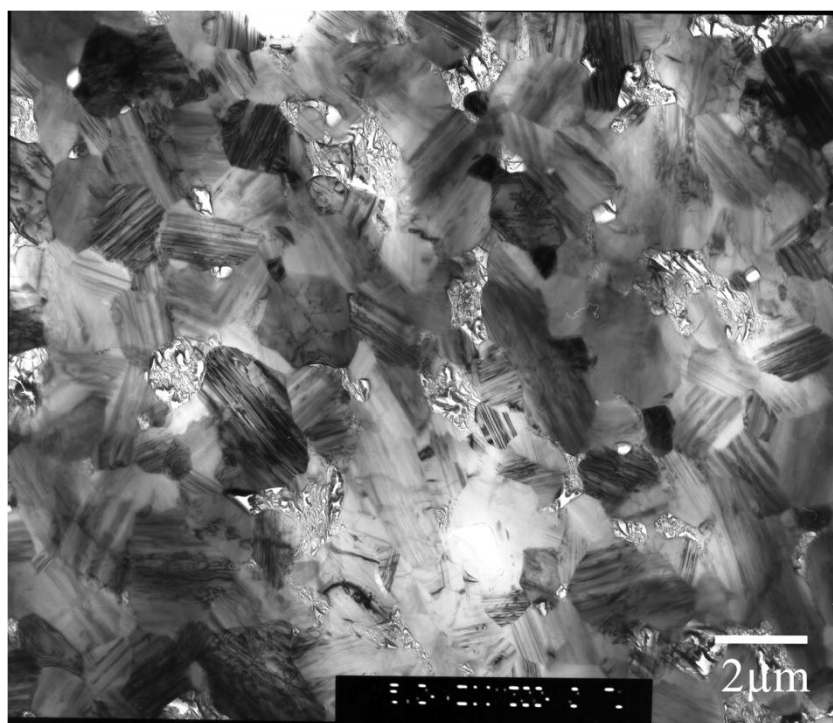


Figure 4. Sinter forging by SPS; 1800 °C, 500 MPa.

2.2 The Effect of the Grain Size on the Deformation at Elevated Temperature

The no-additive SiC ceramics with different grain sizes of 130 and 370 nm were prepared by annealing after HIPing. The strain rate $\dot{\epsilon} > 0$ at elevated temperature is expressed as a function of the applied stress σ and grain size d as

$$\dot{\epsilon}_0 = A \frac{\sigma^n}{d^p} \exp\left(-\frac{Q}{kT}\right), \quad (1)$$

where n is the stress exponent, p is the grain size exponent, Q is the apparent activation energy for deformation, k is Boltzmann's constant, T is the temperature, and A is a constant. The stress exponent value was 2~3 and increased with decreasing strain rate. Such transition of stress exponent has been reported in superplastic zirconia ceramics and explained by the threshold model and/or the interface-controlled diffusion creep model. The origin of the transition of flow stress in SiC is currently unclear.

The flow stresses of SiC with smaller grain sizes were lower than those with larger grain sizes at a strain rate region of $>1 \times 10^{-5} \text{ s}^{-1}$ (figure 5). On the other hand, at a strain rate region of $<1 \times 10^{-5} \text{ s}^{-1}$, the flow stresses of SiC with smaller grain sizes were higher than those with larger grain sizes. Generally, the flow stress increases with increasing grain size in the superplastic deformation region. In this region, the deformation rate is controlled by diffusion. A novel interpretation is required for the inverse grain-size dependence at a lower strain rate. It is possible that dislocation gliding is a possible mechanism of this deformation behavior of SiC.

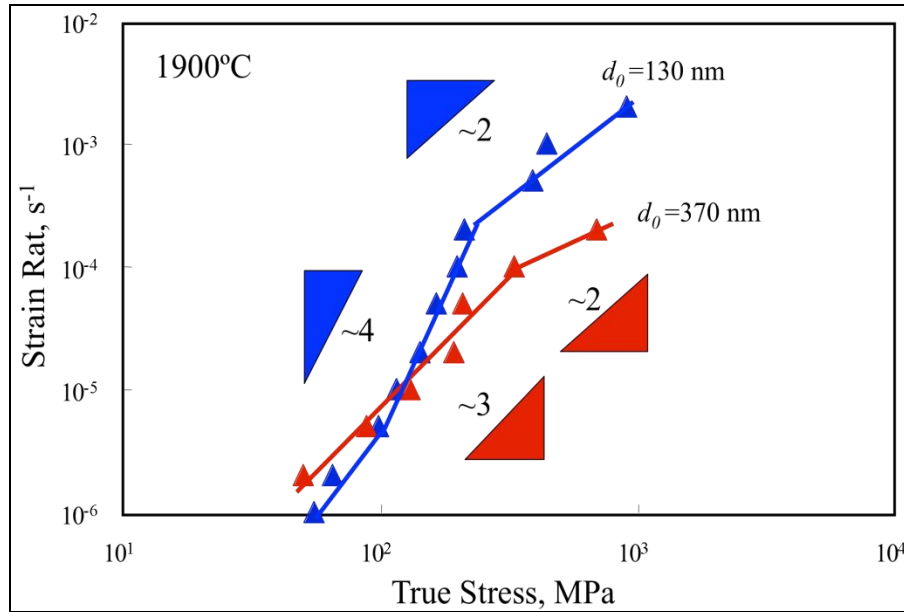


Figure 5. Relationship between stress and strain rate of SiC with different grain sizes.

2.3 Participation and Morphology of Dislocation Activity in Deformation of Nano-SiC Ceramics

Figure 6 indicates the relationship between grain size and calculated shear stress required for nucleation of dislocation in SiC. Because the shear modulus of SiC is very high, the critical shear stress is extremely high. This figure shows that a perfect dislocation was more easily nucleated than the partial dislocation in SiC with a larger grain size. On the other hand, the partial dislocation was more easily nucleated than a perfect dislocation in SiC with a smaller grain size. The critical grain size is ~400 nm. In both types of dislocations, the critical shear stress decreased with increasing grain size. The inverse grain-size dependence at the low stress region in figure 6 may relate to the dislocation activity as nucleation or gliding. Of course, the dominant mechanism of the nano-SiC is grain-boundary sliding. Moreover, the stress level to nucleate the dislocation was much higher than in the present experimental data. Therefore, dislocation gliding itself did not contribute to the total strain. It worked by accommodating stress concentration generated by the grain boundary sliding. If the grain size of nano-SiC were 130 nm, then the partial dislocation would be active.

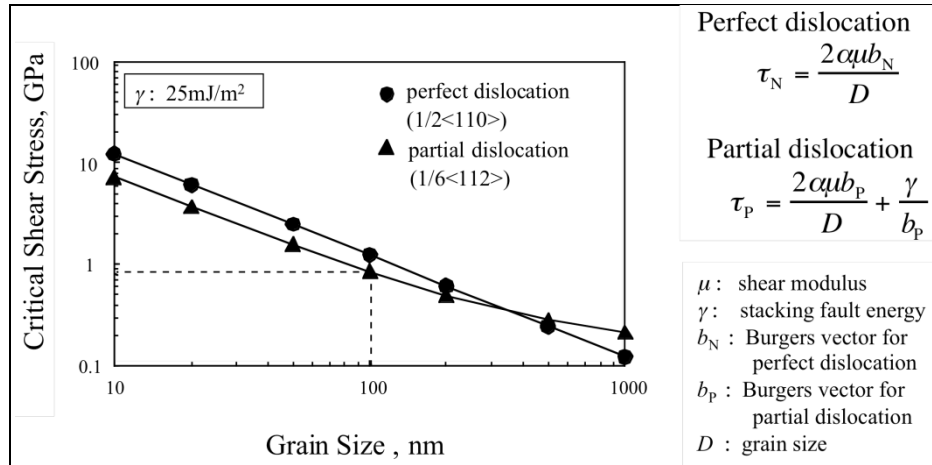


Figure 6. Relationship between grain size and shear stress required for nucleation of dislocation.

Figures 7–9 show transmission electron microscopy (TEM) micrographs of nano-SiC before and after deformation. After large deformation, the boundaries of the individual grains were not well defined and looked blurred, as in figure 2. The strain was stored in the grains. After annealing at 2100 °C, the stored strain seemed to disappear. The dislocations were hard to observe in SiC with the small grains. However, in SiC with the larger grains, they were often observed. We suspected that the movement of partial dislocations was important in the nano-SiC. Because the stacking fault energy of SiC was very low, it was reasonable for us to think that the partial dislocations moved through the nanograin, leaving the stacking faults.



Figure 7. TEM image before deformation.

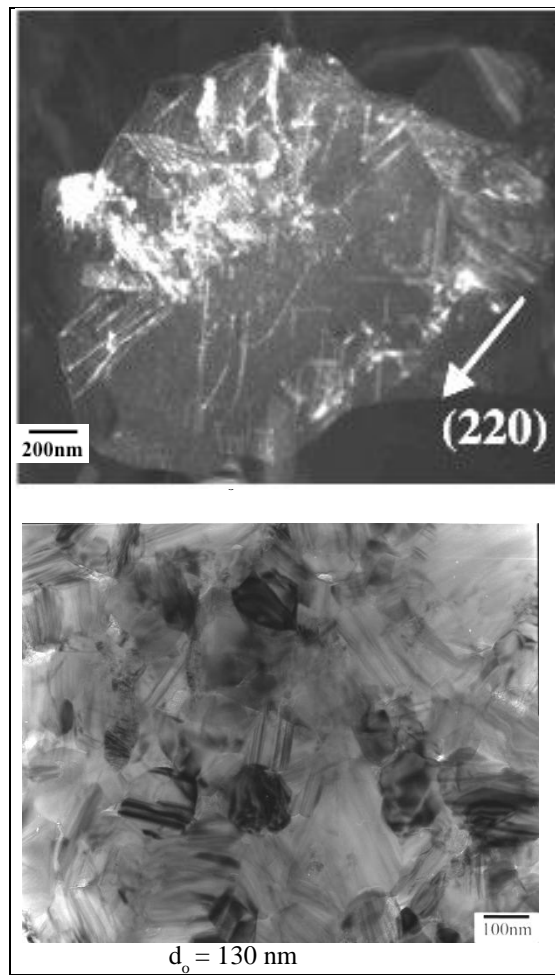


Figure 8. TEM image of deformed SiC
(1900 °C, $1 \times 10^{-4} \text{ s}^{-1}$, $\epsilon = 0.65$).

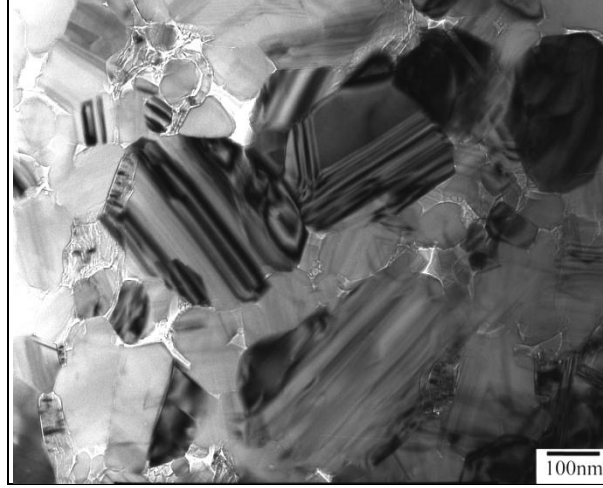


Figure 9. TEM image of annealed SiC (2100 °C, 1 h) after deformation.

2.4 The Effect of Carbon Content on the Deformation at Elevated Temperature

Nanosilicon powder was added to the β -SiC powder in order to control the carbon content. The mixed powder was sintered by hot-pressing to remove the impurity oxygen. The sintering was conducted at 2000 °C and 200 MPa using a SiC mold and SiC punches. The free carbon in SiC reacted with the impurity oxygen and added silicon as follows:

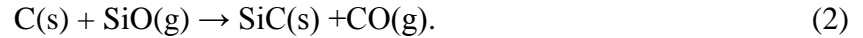


Figure 10 shows SEM micrographs of hot-pressed SiC. The grain size of SiC decreased with increasing the carbon and silicon content. This suggested that the excess carbon and silicon segregated at the grain boundary, decreasing the grain-boundary diffusivity. Such an effect was contrary to boron and oxygen. Table 2 shows the characteristics of hot-pressed SiC. Figure 11 illustrates the relationship between the amount of excess silicon and carbon and grain size.

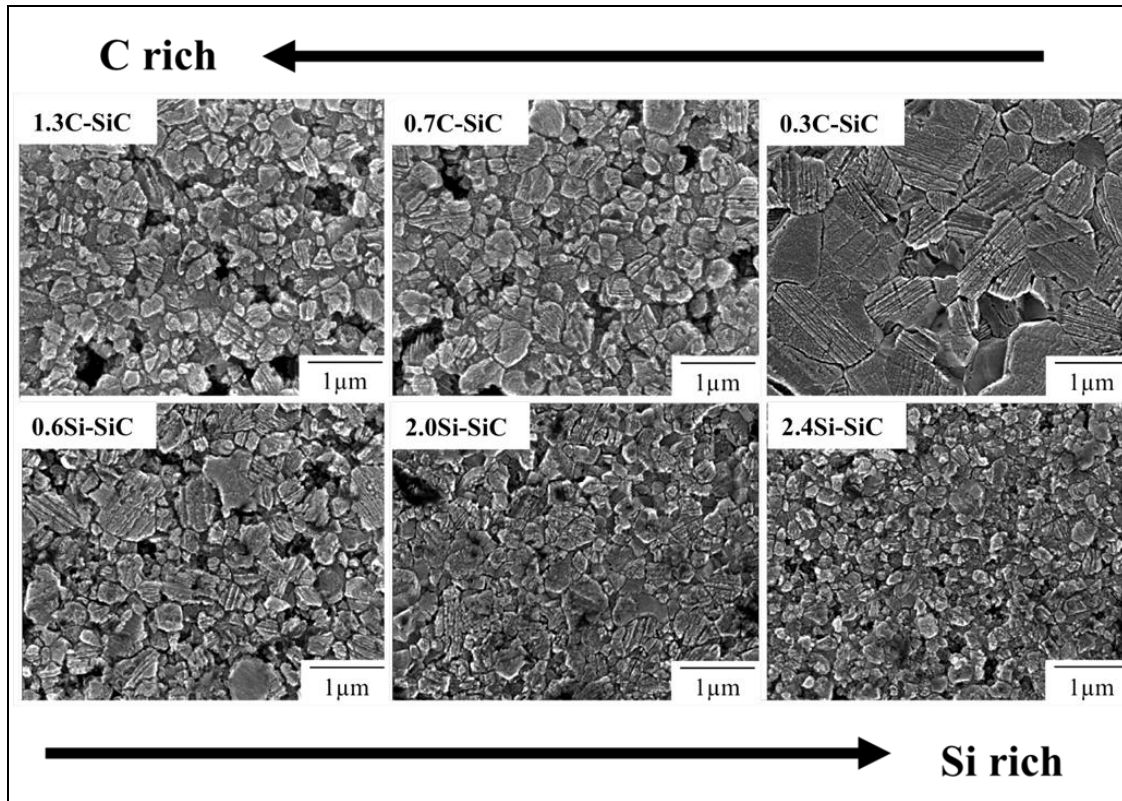


Figure 10. SEM micrographs of hot-pressed SiC.

Table 2. Hot-pressed SiC characteristics.

Designation	Excess Element (mol%)	Grain Size (nm)	Relative Density (%)
1.3C-SiC	1.3 (carbon)	350	95.5
0.7C-SiC	0.7 (carbon)	400	95.2
0.3C-SiC	0.3 (carbon)	760	98.9
0.6Si-SiC	0.6 (silicon)	470	97.4
2.0Si-SiC	2.0 (silicon)	400	98.1
2.4Si-SiC	2.4 (silicon)	270	97.9

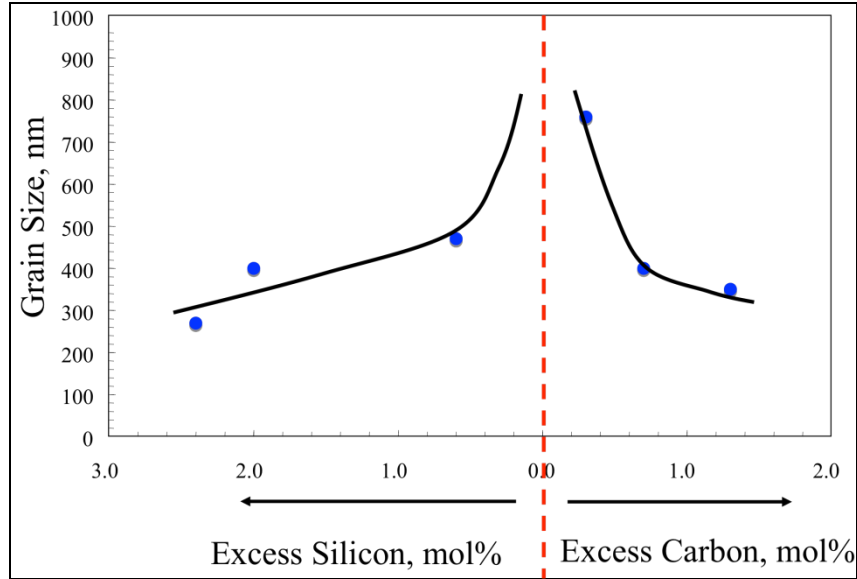


Figure 11. Relationship between the amount of excess carbon and silicon and grain size.

Figure 12 shows the relationship between the stress and strain rate in SiC with a different carbon and silicon content. The stress increased with increasing carbon content in spite of the decrease in grain size. The role of the excess carbon in SiC was quite the opposite of that of boron additive. The stress exponent tended to increase at a higher stress region. In this study, the effects of the excess carbon in pure SiC ceramics on the microstructure and deformation were revealed. The change of the structure and composition at the grain boundary by segregation of carbon atoms was interesting and will be researched in the future.

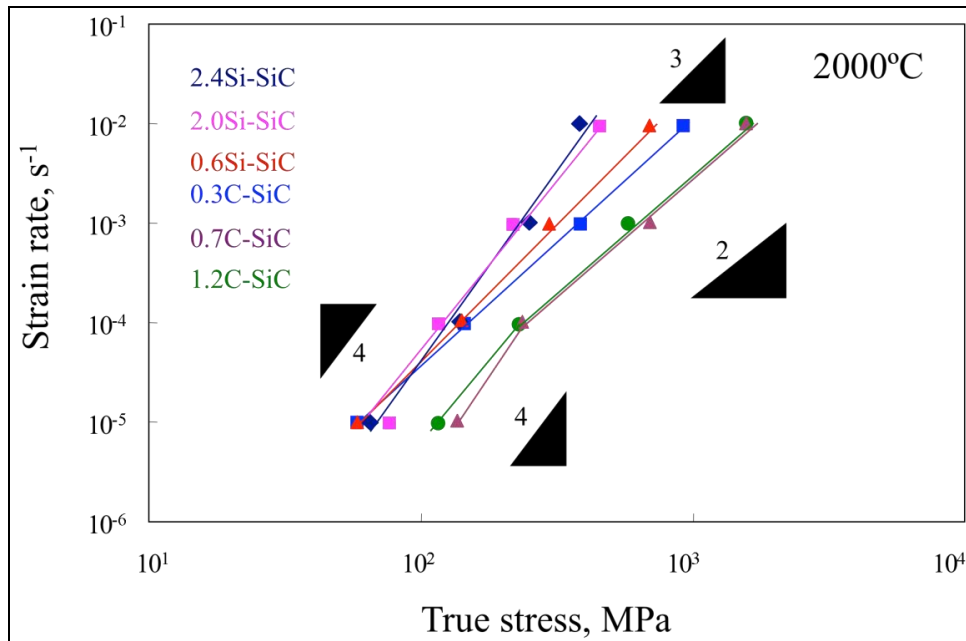


Figure 12. Relationship between stress and strain rate.

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